

IN THE CLAIMS:

1. (Withdrawn) An organic EL panel in which organic EL elements including at least an organic emissive layer are arranged in matrix form between pixel electrodes each having a size corresponding to an emissive region of one pixel and opposing electrodes being opposed to the pixel electrodes, the organic EL panel comprising:

an insulating film in the form of a frame which covers peripheral edges of each of the pixel electrodes, and

a protrusion having a thickness greater than that of said insulating film and provided on the outside of the insulating film.

2. (Withdrawn) An organic EL panel according to claim 1, wherein said protrusion is made of the same material as said insulating film.

3. (Withdrawn) An organic EL panel according to claim 1, wherein said protrusion is configured by arranging a plurality of pillar components so as to discretely surround the periphery of the insulating film.

4. (Withdrawn) An organic EL panel according to claim 1, wherein a recess in the form of a frame from which said insulating film is removed is formed between said insulating film and the protrusion.

5. (Withdrawn) An organic EL panel according to claim 1, wherein said protrusion works as a mask support for bearing a mask for evaporation.

6. (Withdrawn) An organic EL panel according to claim 1, wherein said protrusion works as a support for bearing a donor sheet which releases an organic material by laser irradiation.

7. (Currently Amended) A method of manufacturing an organic EL panel in which organic EL elements are arranged in a matrix, each organic EL comprising at least an organic emissive layer disposed between a pixel electrode and an opposing electrode, wherein each pixel electrode has a size corresponding to an emissive region of one pixel, and wherein the opposing electrode is opposed to each pixel electrode and corresponds to a plurality of pixels, the manufacturing method comprising:

forming the pixel electrodes;

forming insulating films, wherein each insulating film has a form of a frame that covers peripheral edges of each of the pixel electrodes;

forming protrusions around each insulating film, wherein each protrusion has a thickness greater than that of the insulating film around which the protrusions surrounds; **and**

forming a hole transporting layer over the entire area of both the insulating films and the pixel electrodes; and

forming the organic emissive layer while the protrusions are supporting a mask.

8. (Currently Amended) A method of manufacturing an organic EL panel according to claim 7, wherein the insulating films and the protrusions are made of the same material and the forming insulating films and forming protrusions further comprises each insulating film and each protrusion are formed through a two-step exposure process comprising

exposing the insulating films to a first exposure of light to form a thickness of the insulating films;

exposing the insulating films to a second exposure of light, wherein areas of the insulating film forming the protrusions are not exposed to both the first exposure of light and the second exposure of light; and

removing portions of the insulating films exposed to the first exposure of light and the second exposure of light.

~~a first exposure to light for forming the thickness of the insulating film and a second exposure to light for removing the insulating film.~~

9. (Currently Amended) A method of manufacturing an organic EL panel according to claim 7, wherein the insulating films and the protrusions are made of the same material and the forming insulating films and forming protrusions further comprises

masking the insulating film with a gray tone mask having openings,

~~wherein each insulating film and each protrusion are formed through a gray tone exposure processing of a region where the insulating film is formed such that light exposure to the insulating films varies among a portion of the region from which the insulating film is removed, a portion of the region on which the insulating film is provided, and a portion of the region on which the protrusions are provided.~~

10. (Currently Amended) A method of manufacturing an organic EL panel in which organic EL elements are arranged in a matrix, each organic EL comprising at least an organic emissive layer disposed between a pixel electrode and an opposing electrode, wherein each pixel electrode has a size corresponding to an emissive region of one pixel, and wherein the opposing electrode is opposed to each pixel electrode and corresponds to a plurality of pixels, the manufacturing method comprising:

forming the pixel electrodes;

forming insulating films, wherein each insulating film has a form of a frame that covers peripheral edges of each of the pixel electrodes;

forming protrusions around each insulating film, wherein each protrusion has a thickness greater than that of the insulating film; and

forming a hole transporting layer over the entire area of both the insulating films and the pixel electrodes; and

forming the organic emissive layer such that, while the protrusions are supporting a donor sheet on which a layer made of an organic emissive material is formed, the organic emissive material is released from the donor sheet by laser irradiation so as to be deposited on the pixel electrodes.

11. (Currently Amended) A method of manufacturing an organic EL panel according to claim 10, ~~wherein each insulating film and each protrusion are formed through a two-step exposure process comprising a first exposure to light for forming the thickness of the insulating film and a second exposure to light for removing the insulating film. the insulating films and the protrusions are made of the same material and the forming insulating films and forming protrusions further comprises~~

exposing the insulating films to a first exposure of light to form a thickness of the insulating films;

exposing the insulating films to a second exposure of light, wherein areas of the insulating film forming the protrusions are not exposed to both the first exposure of light and the second exposure of light; and

removing portions of the insulating films exposed to the first exposure of light and the second exposure of light.

12. (Currently Amended) A method of manufacturing an organic EL panel according to claim 10, wherein the insulating films and the protrusions are made of the same material and the forming insulating films and forming protrusions further comprises

masking the insulating film with a gray tone mask having openings,

~~wherein each insulating film and each protrusion are formed through a gray tone exposure processing of a region where the insulating film is formed such that light exposure to the insulating films varies among a portion of the region from which the insulating film is removed, a portion of the region on which the insulating film is provided, and a portion of the region on which the protrusion is provided.~~

13. (New) A method of manufacturing an organic EL panel according to claim 7, wherein the protrusions each comprise a line shape extending through a plurality of pixels.

14. (New) A method of manufacturing an organic EL panel according to claim 7, wherein the line shape is a continuous line shape.

15. (New) A method of manufacturing an organic EL panel according to claim 10, wherein the protrusions each comprise a line shape extending through a plurality of pixels.

16. (New) A method of manufacturing an organic EL panel according to claim 10, wherein the line shape is a continuous line shape.